

Product Datasheet

CVD Graphene Cu Substrate

Properties

Chemical name: CVD Graphene

Graphene film:

- Growth method: CVD synthesis
- Appearance (color): Transparent
- Transparency: > 97%
- Coverage: 92% monolayer + 8% bilayer
- Thickness (theoretical): 0.345 nm

Substrate Cu foil:

- Thickness: 25 μm
- Purity: 99.8%
- Sample size: 1x1cm²

Characterization

